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PPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/617,578	07/11/2003	Steven P. Nally	108298533US1	3549	
25096 75	90 02/13/2006		EXAMINER		
PERKINS COIE LLP			ALANKO, ANITA KAREN		
PATENT-SEA P.O. BOX 1247			ART UNIT	PAPER NUMBER	
SEATTLE, WA 98111-1247			1765		
			DATE MAILED: 02/13/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

		1 4 11 41				X			
		Application	on No.	Applicant(s)					
Office Action Comments		10/617,57	78	NALLY ET AL.					
	Office Action Summary	Examiner		Art Unit					
		Anita K. A		1765					
Period fo	The MAILING DATE of this communication r Reply	appears on the	cover sheet with the c	orrespondence ad	ddress				
THE I - Exter after - If the - If NO - Failur Any r	ORTENED STATUTORY PERIOD FOR REMAILING DATE OF THIS COMMUNICATIOns is signated as a signature of time may be available under the provisions of 37 CF SIX (6) MONTHS from the mailing date of this communication period for reply specified above is less than thirty (30) days, a period for reply is specified above, the maximum statutory period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by signature of the period by the Office later than three months after the need patent term adjustment. See 37 CFR 1.704(b).	DN. R 1.136(a). In no even a reply within the statueriod will apply and within the apple	ent, however, may a reply be time story minimum of thirty (30) days Il expire SIX (6) MONTHS from ication to become ABANDONE	nely filed s will be considered timel the mailing date of this c D (35 U.S.C. § 133).	ly. ommunication.				
Status									
1) 🛛	Responsive to communication(s) filed on 1	1/14/05 amdt.							
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	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.								
Dispositi	on of Claims								
4)⊠ 5)□ 6)⊠ 7)□	Claim(s) 22-25,49-52 and 56-62 is/are penda) Of the above claim(s) is/are with Claim(s) is/are allowed. Claim(s) 22-25,49-52 and 56-62 is/are rejection is/are objected to. Claim(s) is/are subject to restriction are	drawn from cor	nsideration.						
Application	on Papers								
9)[] -	The specification is objected to by the Exan	niner.							
10) 🗌 -	The drawing(s) filed on is/are: a)	accepted or b)	objected to by the E	Examiner.					
	Applicant may not request that any objection to	the drawing(s) b	e held in abeyance. See	37 CFR 1.85(a).					
_	Replacement drawing sheet(s) including the course file oath or declaration is objected to by the		•		` '	•			
Priority u	nder 35 U.S.C. § 119								
12)	Acknowledgment is made of a claim for fore All b) Some * c) None of: 1. Certified copies of the priority documed according to the priority document of the priority docume	nents have been nents have been priority docume reau (PCT Rule	n received. In received in Application Ints have been received Into 17.2(a)).	on No d in this National	Stage				
Attachment	(s)								
	of References Cited (PTO-892)		4) Interview Summary	•					
3) 🔲 Inform	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB No(s)/Mail Date		Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:		D-152)				

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Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

Claim 22 is rejected under 35 U.S.C. 102(a) as being anticipated by Canella et al (US 5,997,388).

Canella discloses a method (col.8, lines 42+) comprising etching (using a de-marking head 55 comprising a bladed mill, a sanding disk, a sanding head or similar device) at least a portion of the surface ("controlled mark removal" col.8, line 76) to remove a layer of material from the package and form a marking surface; and

cleaning residual materials (system 24, col.10, lines 27-29) from the package after terminating the etching of the package surface.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any

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evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 22-23, 25, 49-50, 52, 56, 58-62 rejected under 35 U.S.C. 103(a) as being unpatentable over Canella et al (US 5,997,388) in view of Eom et al (KR 426119B).

The discussion of Canella from above is repeated here. Canella discloses etching, but does not disclose chemical etching. Eom teaches that a useful alternative technique for removing surface molding resin of a packaged semiconductor by a mechanical milling/etching method is to use a chemical etching method (see abstract, "Novelty" section). After the etching, Eom teaches to clean (last line of abstract). It would have been obvious to one with ordinary skill in the art to chemically etch and then clean to remove surface material in the method of Canella because Eom teaches that this is a useful alternative technique to mechanical removal.

Further, as to claim 23, Examiner takes official notice that HF is a conventional etchant. It would have been obvious to one with ordinary skill in the art to use HF to etch in the modified method of Canella because it is a conventional etching composition.

As to claim 25, since the modified method of Canella has controlled removal of a mark, it would have been obvious to one with ordinary skill in the art to control the depth to move undesired surface features such as blemishes, thereby obtaining a desired surface finish, because chemical etching allows for control over the rate of etching by controlling the composition, delivery and parameters of etching.

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As to claim 49, Canella discloses to process several substrates (col.11, lines 38-45), but does not disclose to cut the common substrate to separate the devices from one another. It would, however, would have been obvious to do this since processing several devices at once saves time and a common substrate would provide a helpful means to handle and process a plurality of small devices at one time.

Claims 24, 51 and 57 are rejected under 35 U.S.C. 103(a) as being unpatentable over the combination of Canella et al (US 5,997,388) and Tsuchiko et al (JP 01-067346 A).

As to claim 24, Tsuchiko teaches that a useful technique for removing material from the surface 4 of packages 2 comprises etching 7 through a mask 5 (see abstract). Tsuchiko does not disclose to clean after etching. The discussion of Canella from above is repeated here.

It would have been obvious to one with ordinary skill in the art to clean after etching in the method of Tsuchiko because Canella teaches that this is useful to do after etching.

Response to Amendment

Applicants arguments filed 11/14/05 are persuasive. The rejection over Martin is withdrawn since Martin is directed to decapsulating for test and repair – not to form a mark surface. The rejection using Carson is withdrawn because of applicant's statement that Carson and the instant invention were commonly owned at the time the invention was made.

The claims are now rejected over Canella et al, Eom et al and Tsuchiko et al. As broadly interpreted, Canella discloses etching since the claims are not limited to chemical etching. Eom

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is newly cited to teach that chemical etching to remove packaging material from microelectronic devices is a useful technique as discussed in the rejection above.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Mardi is cited for teaching removing marks with a laser. Samonides is cited for etching to form marks on printed circuit boards. Kwon et al (KR 97008549 A) is cited for removing marks from a semiconductor package.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anita K. Alanko whose telephone number is 571-272-1458. The examiner can normally be reached on Mon-Fri until 2:30 pm (Wed until 11:30).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571-272-1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306:

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Anita K. Hanko

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Primary Examiner
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